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- (54) Process for the synthesis of fullerenes.
- A process is disclosed to synthesize fullerenes in a plasma reactor (10). It comprises introducing various amounts of carbon halides as the plasma forming gas in a plasma torch (12) capable of producing a high enough temperature flame (22) to dissociate the carbon bearing molecules into carbon and halogen atoms, hence forming a carbon cloud which condenses into a soot (18) containing fullerenes. Also hydrocarbons and/or inert gases can be introduced in the torch (12) as the plasma forming gas and reacted with carbon halides or halogens injected therewith or directly into the plasma flame (22) at the exit of the torch (20). The process can use a high enthalpy nontransferred d.c. plasma torch or an induction plasma torch as the plasma generating device. Soot having 1 to 10% by weight of a C_{60} fullerene or an admixture of C_{60} and C_{70} fullerenes is thereby produced.

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BACKGROUND OF THE INVENTION

1. Field of the Invention

This invention provides a new process for the synthesis of fullerenes (a family of carbon molecules). More particularly, the invention provides a process whereby fullerenes are produced by dissociating a carbon halide or a hydrocarbon using a plasma torch.

2. Brief Description of the Prior Art

Until recently, only two forms of carbon were known to exist: graphite and diamond. In graphite the carbon atoms form sheets stacked on top of each other while in diamond, each carbon atom is covalently bonded to four other carbon atoms forming a giant network of small pyramids.

Another form of carbon, the "fullerenes", has lately been successfully synthesized and identified. Basically, fullerenes are hollow molecules made up of curled-up graphitic sheets. These carbon molecules can contain anywhere from 32 to 980 carbon atoms and are all believed to have the structure of geodesic domes. The name "fullerenes" was chosen in honour of Buckminster Fuller who developed the structure of the geodesic dome. The molecules are also called "buckminsterfullerenes" or "buckyballs" for short. The molecules containing 60 carbon atoms (Ceo) are considered to be the most important due to their high stability. Molecules containing 70 carbon atoms (C70) are also highly stable. Hence, "buckyballs" often refer to C₆₀ and/or C₇₀. Molecules containing very large numbers of carbon atoms are also called "hyperfullerenes°.

In 1985, Robert F. Curl and Richard E. Smalley of Rice University working with Harold W. Kroto of the University of Sussex, found that a new form of carbon, C_{60} , could be made by vaporizing graphite in helium using a pulsed laser beam. The production rate of fullerenes using this technique is, however, extremely slow (few grams/day).

In May 1990, five years later, Wolfgang Kratschmer and Donald Huffman were the first to observe and positively identify this molecule. At a conference in Germany in early September of 1990, Kratschmer and Huffman announced that they had found a much simpler way to synthesize C₆₀. They were able to make fullerenes by striking an arc between two graphite electrodes and collecting the soot formed from the vaporized carbon. However, with a production rate of roughly 1 gram/hour, the arc vaporization of graphite is also a very slow process.

Several recent articles describe fullerenes and their uses and potential applications. For example, in the article by Edward Edelson entitled "BUCKYBALL - The Magic Molecule", published in Popular Science, August 1991, a good review of the discovery, meth-

ods of production and uses of fullerenes or "bucky-balls" is made. An article by Robert F. Curl and Richard E. Smalley entitled "Fullerenes" in Scientific American for October 1991 discusses the difficulties encountered in producing "visible amounts" of fullerenes and describes the carbon arc method for making the product in microscopic quantities. Another good description in particular of C₆₀ fullerenes is provided in Chemical Reviews 1991 of the American Chemical Society by Kroto et al., pp 1213-1235, which, among other things describes the isolation, separation and structure characterization of the most useful fullerenes - C₆₀ and C₇₀.

Currently the most interesting uses of bulk C₆₀ and C₇₀ fullerenes are in electronics, where in various compound forms they can act as an insulator, a battery, a conductor, a semiconductor or a superconductor. Also fullerenes offer interesting opportunities in the plastic and pharmaceutical industries, although their use has been rather restricted until now because of the difficulty to produce them in sufficiently large quantities and at a reasonable price.

BRIEF SUMMARY OF THE INVENTION

It was an object of the present inventors to obviate the difficulties of known processes for the production of fullerenes and to provide a novel process capable of making this product at a much faster rate than was possible hitherto.

The invention also makes it possible to safely utilize environmentally objectionable substances, i.e. the CFCs or carbon halides and to transform them into a highly desirable product, namely fullerenes. In this regard, one should realize that in North America alone there are presently more than a million tons of CFCs in refrigerators, cars, etc. They must be collected and destroyed without releasing them into the atmosphere, to avoid depletion of the ozone layer. The process of this invention provides an opportunity for so doing in a safe, efficient and useful manner.

The novel process in accordance with the present invention comprises introducing a carbon and halogen bearing gas or gases, such as carbon halides (compounds of carbon and chlorine, fluorine, bromine and/or iodine), which are also popularly called CFCs, directly into a plasma reactor as the plasma forming gas or injecting such carbon halides or halogens at the exit of the plasma torch in the plasma flame and reacting them with hydrocarbons and/or inert gases used as the plasma forming gas. Obviously mixtures of carbon halides or halogens with hydrocarbons and/or inert gases can also be used. When a, carbon halide is used as the plasma forming gas, the energy of the plasma flame dissociates the carbon bearing, molecules into carbon and halogen atoms. The carbon-carbon bonds are much more stable than the carbon-halogen bonds at high temperature. Conse-

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quently, a carbon cloud is formed in which carbon atoms recombine to form fullerenes and other carbon molecules, while the halogens leave the reactor in the off-gas. If a hydrocarbon is used as the plasma forming gas, the halogen atoms will act as "H getter" and ensure that few C-H bonds are formed upon cooling. The carbon atoms which condense, form soot containing a significant amount of fullerenes, which is normally higher than 1% by weight and is usually in the range of 2 to 10% by weight, depending on the operating conditions. Extraction of the fullerenes from the soot can be done in the known manner, for example as described in the article by Deborah Holmes Parker et al. entitled "High-Yield Synthesis, Separation, and Mass-Spectrometric Characterization of Fullerenes C₆₀ to C₂₆₆" published in the J. Am, Chem. Soc. 1991. 113, 7499-7503.

The efficiency, in terms of fullerenes content in scot, was observed to be higher when the carbon halide was used as the plasma forming gas as compared to introducing the halogen in the tail flame of a hydrocarbon plasma.

One of the main novel aspects of the present invention lies in the formation of a carbon cloud when the plasma flame dissociates the molecules of the gases employed in the process, generally at temperatures between about 5000°C and 20,000°C, into carbon and halogen atoms. By controlling the chemistry and plasma torch conditions, such as power and voltage, the process is made to enhance the formation of only C-C bonds. Once the carbon cloud is formed, the annealing of fullerenes takes place in a generally known manner at a temperature between about 1000°C and about 1500°C as disclosed, for example, by R.E. Smalley in the article entitled "Self-Assembly of the Fullerenes" published in Acc. Chem. Res., 1992, 25, 98-105, p. 103. This temperature range is not strictly limitative since it may vary depending on the type or combination of fullerenes desired and the operating pressure of the reactor; normally it will be between 700°C and 1600°C. The required temperature for producing the fullerenes can thus be readily determined and used by a person skilled in the art.

The main advantage of this new process is that it can produce fullerenes at a much faster rate (by several orders of magnitude faster) and much more economically than anything presently known.

The intense heat generated by the plasma has been used commercially for many years to partly dissociate methane and produce acetylene. In the commercial production of acetylene, a low enthalpy plasma torch is used. However, when a high enthalpy plasma torch is employed, the carbon halides or hydrocarbons break down completely to form carbon atoms which condense and form soot on both a hot substrate and on a cold surface such as a water cooled. wall. The soot contains significant amounts of fullerenes.

In essence, therefore, the process of the present invention for the synthesis of fullerenes comprises: (a) feeding a plasma forming gas into a reactor and generating a plasma within said reactor in the form of a plasma flame, said plasma forming gas being selected from a carbon halide gas, combinations of a halogen containing gas and a hydrocarbon gas, and combinations of an inert gas with a carbon halide gas or a halogen containing gas and a hydrocarbon gas; (b) dissociating said plasma forming gas in said plasma flame into carbon and halogen atoms produced in the form of a cloud; and (c) allowing the carbon atoms in said cloud to recombine and condense as soot on a surface outside of said plasma flame, said soot containing the fullerenes. The plasma flame may be generated using a hydrocarbon gas or an inert gas, such as helium or argon, and the halogen containing gas may be selected from a halogen gas and a carbon halide gas and may be introduced into the reactor in admixture with the hydrocarbon gas and/or the inert gas or injected directly into the plasma flame.

BRIEF DESCRIPTION OF THE DRAWINGS

Preferred embodiments of the invention will now be described with reference to the drawings in which:-

Fig. 1 illustrates a diagram of a plasma torch reactor used to carry out the process of the present invention:

Fig. 2 represents mass spectrometry results when a carbon halide gas is used as the plasma forming gas;

Fig. 3 represents mass spectrometry results when a hydrocarbon is used as the plasma forming gas and a halogen is introduced into the tail flame:

Fig. 4 represents mass spectrometry results when another carbon halide gas is used as the plasma forming gas; and

Fig. 5 represents mass spectrometry results when an inert gas is used as the plasma forming gas.

45 DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

Referring to the drawings, in Figure 1 there is shown a reactor 10 in which there is mounted a high enthalpy plasma torch 12 which may be of the type disclosed in U.S. Patent No. 5,147,998 issued September 15, 1992, consisting of two coaxial tubular electrodes mounted within a housing with a gap between the two electrodes. Other plasma generating devices can also be used, including d.c. plasma guns and induction plasma torches and they are also schematically illustrated by torch 12. The plasma forming gas 24 can contain various predetermined amounts of carbon halides (e.g. CCl₄, CF₄, CBrF₃, Cl₄, CCl₂F_{2...})

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which are normally used in combination with inert gas such as helium. Alternatively the plasma forming gas 24 can contain various predetermined amounts of hydrocarbons (CH₄, C₂H₂,...) and the carbon halides can be introduced either in admixture therewith or at the exit of the plasma torch into the tail flame through opening 20. Halogens may also be introduced in admixture with the plasma forming gas 24 or through this opening 20 in lieu of or in addition to carbon halides. In this case the plasma forming gas may again be combined with an inert gas such as helium. The halogen containing gas introduced through opening 20 may also be combined with an inert gas such as argon. These combinations of reactive gases with inert gases are generally known in the art of plasma technology. The energy of the plasma flame 22 dissociates the carbon bearing molecules into C and F, Cl, Br, H or I atoms producing a cloud. The carbon atoms then condense on a collecting device 14 or the reactor wall 16 to form a soot 18 which contains a significant amount of fullerenes.

The invention will further be described by reference to the following non-limitative examples:

EXAMPLE 1

The following conditions were used in an experiment where a carbon halide was employed as the plasma forming gas:

Plasma Torch: Non-transferred D.C. Torch

Plasma Gas: = 10-20 vol.% CBrF3 (Freon 13B1) +

Helium (bal.)

Injection of gas at exit of the torch: None Operating Pressure: Atmospheric (101.3 kPa)

Plasma Gas Flow Rate: 50-70 L/min.

Operating Voltage: 200-300 V

Power: 50-70 kW

Under the above conditions 6.2 grams of soot were produced in approximately 1 minute. Mass spectrometry analysis performed on the soot revealed that it contained significant amounts of C60 and C70. The mass spectrometry results for this Example 1 are presented in Figure 2 and show peaks for C60 and C70 at 721.1 and 840.1 respectively.

EXAMPLE 2

The following conditions were used in an experiment where a hydrocarbon was employed as the plasma forming gas and a halogen was injected at the exit of the plasma torch:

Plasma Torch: Non-transferred D.C. Torch Plasma Gas: = 5-10 vol.% C_2H_2 (acetylene) + Helium

Injection of gas at torch exit Chlorine (10 L/min) + Ar-

Operating Pressure: Atmospheric (101.3 kPa) Plasma Gas Flow Rate: 180-200 L/min.

Operating Voltage: 250-300 V

Power: 40-60 kW

Under the above conditions 60.8 grams of soot were produced in approximately 4 minutes. Mass spectrometry analysis on the soot revealed that it contained about half as much of C₈₀ as Example 1 and no C₇₀. The mass spectrometry results for this Example 2 are presented in Figure 3 where the peak at 721 confirms the presence of C60.

EXAMPLE 3

The following conditions were used in an experiment where a carbon halide was again used as the plasma forming gas:

Plasma Torch: Non-transferred D.C. Torch Plasma Gas: 8-10 Vol.% C2Cl4 in helium (bal.)

Injection of gas at exit of the torch: None Operating Pressure: Atmospheric

Plasma Gas Flow Rate: 120-135 L/min.

Operating Voltage: 135-190 V

Power: 25-40 kW

Under the above conditions 8 grams of soot were collected in 3 minutes. A chromatographic extraction was 25 performed on the soot and revealed that the fullerenes content therein was about 5% by weight. Amass spectroscopy scan on the scot is presented in Fig. 4. The peaks for C_{80} and C_{70} are shown at 720 and 840. Higher fullerenes are also present in the soot, as can 30 be seen from other peaks in the figure.

EXAMPLE 4

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The following conditions were used in an experiment where an inert gas, namely helium, was used as the plasma forming gas:

Plasma Torch: Non-transferred D.C. Torch

Plasma Gas: Helium

Injection of gas at exit of torch: 8 L/min C2Cl4

Operating pressure: atmospheric Plasma gas flow rate: 180-200 L/min Operating Voltage: 170-200 V

Power: 35-40 kW.

Under the above conditions 16.3 grams of soot were collected in 6 minutes. A mass spectrometry scan on the soot is presented in Fig. 5. The peaks for C_{60} and C70 are shown at 720 and 841 respectively.

The above description and the given examples represent preferred embodiments which are by no means limitative. Various modifications that would be obvious to those skilled in the art can be made without departing from the present invention.

Claims

1. A process for the synthesis of fullerenes, which comprises:

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a) feeding a plasma forming gas into a reactor (10) and generating a plasma within said reactor in the form of a plasma flame (22), said plasma forming gas being selected from a carbon halide gas, combinations of a halogen containing gas and a hydrocarbon gas, and combinations of an inert gas with a carbon halide gas or with a halogen containing gas and a hydrocarbon gas;

 b) dissociating said plasma forming gas in said plasma flame (22) into carbon and halogen atoms produced in the form of a cloud;

c) allowing the carbon atoms in said cloud to recombine and condense as soot (18) on a surface (14, 16) outside of said plasma flame, said soot containing the fullerenes.

2. A process as defined in claim 1, wherein the inert gas is selected from helium and argon.

 A process as defined in claim 1 or 2, wherein the halogen containing gas is selected from a halogen gas and a carbon halide gas.

A process as defined in claim 3, wherein the halogen gas is chlorine.

- 5. A process as defined in claims 1 or 3, wherein the carbon halide gas is a CFC.
- A process as defined in claim 1 or 3 wherein the carbon halide gas is CBrF₃ or C₂Cl₄.

 A process as defined in any one of claims 1 to 6, wherein the halogen containing gas is injected directly into the plasma flame.

- A process as defined in any one of claims 1 to 6, wherein the inert gas is used to generate the plasma flame and the carbon halide gas is injected directly into said plasma flame.
- 9. A process as defined in any one of claims 1 to 6, wherein the inert gas is used to generate the plasma flame and the halogen containing gas with the hydrocarbon gas are injected directly into said plasma flame.
- 10. A process as defined in claim 7, 8 or 9, wherein the gases injected into the plasma flame are injected in combination with an inert gas, such as argon or helium.
- 11. A process as defined in any one of claims 1 to 10, wherein the reactor uses a non transferred d.c. plasma torch or an induction plasma torch to form the plasma flame.

12. A process as defined in any one of claims 1 to 11, wherein a C_{60} fullerene or a mixture of C_{60} and C_{70} fullerenes is thereby produced.

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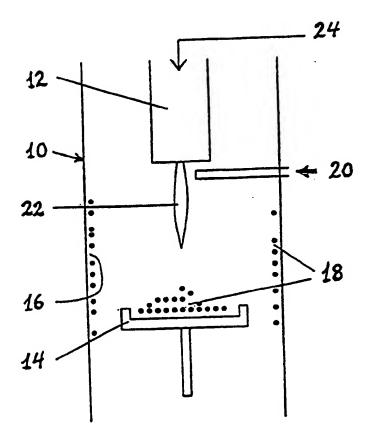


Fig. 1

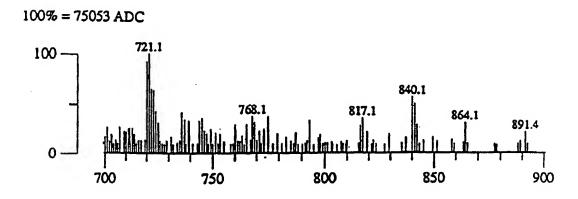


Fig. 2

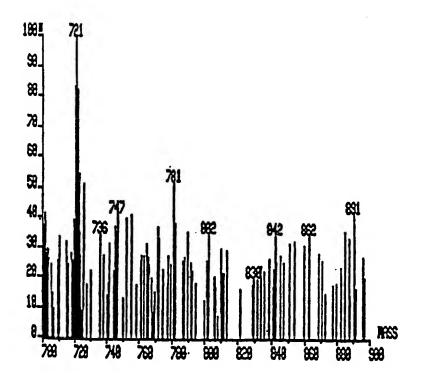


Fig. 3

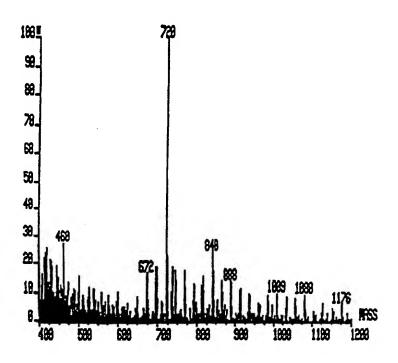


Fig. 4

 $\int_{\mathbb{R}^{n}} dx$

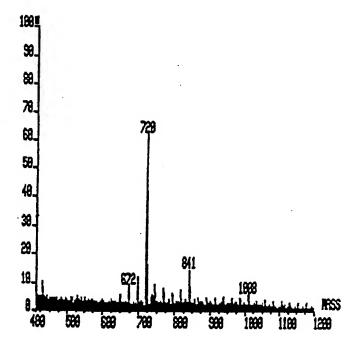


Fig. 5



EUROPEAN SEARCH REPORT

Application Number

EP 93 30 2264

	DOCUMENTS CONSI	DERED TO BE RELEVAN	<u> </u>	
Category	Citation of decument with in of relevant pas		Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl.5)
D,A	JOURNAL OF THE AMERICAN CHEMICAL SOCIETY vol. 113, no. 20, 1991, WASHINGTON, DC US pages 7499 - 7503 D.H.PARKER ET AL.			C01B31/02
D,A	SCIENTIFIC AMERICAN vol. 265, no. 4, October 1991, NEW YORK US pages 32 - 41 R.F.CURL ET AL.			
D,A	ACCOUNTS OF CHEMICAL vol. 25, no. 3, Mar- pages 98 - 105 R.E.SMALLEY	L RESEARCH ch 1992, WASHINGTON US		
P,A	DATABASE WPIL Week 9307, Derwent Publications Ltd., London, GB; AN 93-055086 & JP-A-5 004 810 (SEMICONDUCTOR ENERGY LAB) 14 January 1993 * abstract *		1	TECHNICAL FIELDS SEARCHED (Int. CL5)
	abstract a			CO1B
	The present search report has			
	Place of search THE HAGUE	Date of completion of the search 04 JUNE 1993		BREBION J.C.
X : particularly relevant if taken alone Y : particularly relevant if combined with another éscument of the same category A : technological background		E : earlier patent after the filing nother D : document cite L : document cite & : member of th	T: theory or principle underlying the invention E: earlier patent document, but published on, or after the filing date D: document cited in the application L: document cited for other reasons A: member of the same patent family, corresponding document	